

Title (en)

A combined adhesion promotion and direct metallization process

Title (de)

Kombinierter Adhesionsverbesserung- und direkter Metallisierungsverfahren

Title (fr)

Procédé combiné pour promouvoir l'adhésion et la métallisation directe

Publication

**EP 1281792 A3 20040707 (EN)**

Application

**EP 02255413 A 20020801**

Priority

GB 0118870 A 20010802

Abstract (en)

[origin: EP1281792A2] A combined adhesion promotion method of a metal to a non-conductive substrate and directly metallizing the non-conductive substrate with the metal. The method involves texturing a non-conductive substrate with a cobalt etch followed by applying a sulfide to the textured non-conductive substrate to provide an electrically conductive surface on the non-conductive substrate. After the surface of the non-conductive substrate has been made electrically conductive, the surface of the non-conductive substrate can be directly metallized. The method reduces the number of process steps for direct metallization of a non-conductive substrate. Thus, the method is more efficient in contrast to conventional methods of metallizing a non-conductive substrate.

IPC 1-7

**C25D 5/56**

IPC 8 full level

**C25D 5/54** (2006.01); **C25D 5/56** (2006.01); **H05K 3/18** (2006.01)

CPC (source: EP KR US)

**C25D 5/56** (2013.01 - EP KR US); **H05K 3/188** (2013.01 - EP US); **H05K 3/188** (2013.01 - KR)

Citation (search report)

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- [DY] EP 0913498 A1 19990506 - SHIPLEY CO LLC [US]
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Designated contracting state (EPC)

AT BE BG CH CY CZ DE DK EE ES FI FR GB GR IE IT LI LU MC NL PT SE SK TR

DOCDB simple family (publication)

**EP 1281792 A2 20030205; EP 1281792 A3 20040707;** CN 1266314 C 20060726; CN 1408903 A 20030409; GB 0118870 D0 20010926;  
JP 2003183881 A 20030703; KR 20030013321 A 20030214; TW 593791 B 20040621; US 2003047458 A1 20030313; US 6790334 B2 20040914

DOCDB simple family (application)

**EP 02255413 A 20020801;** CN 02152913 A 20020802; GB 0118870 A 20010802; JP 2002225337 A 20020801; KR 20020045744 A 20020802;  
TW 91117272 A 20020801; US 21053502 A 20020802